

DATA SHEET

BF1105; BF1105R; BF1105WR
N-channel dual-gate MOS-FETs

Product specification

1997 Dec 02

Supersedes data of 1997 Dec 01

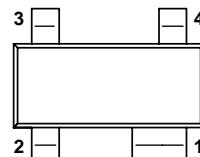
File under Discrete Semiconductors, SC07

N-channel dual-gate MOS-FETs**BF1105; BF1105R; BF1105WR****FEATURES**

- Short channel transistor with high forward transfer admittance to input capacitance ratio
- Low noise gain controlled amplifier up to 1 GHz.
- Internal self-biasing circuit to ensure good cross-modulation performance during AGC and good DC stabilization.

PINNING

PIN	DESCRIPTION
1	source
2	drain
3	gate 2
4	gate 1



Top view MSB035

BF1105 marking code: NAp.

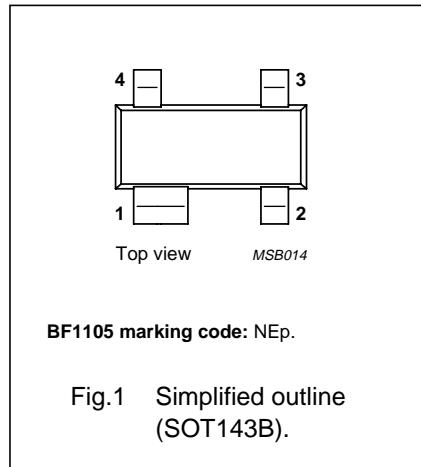
Fig.2 Simplified outline (SOT143R).

APPLICATIONS

- VHF and UHF applications with 5 V supply voltage, such as television tuners and professional communications equipment.

DESCRIPTION

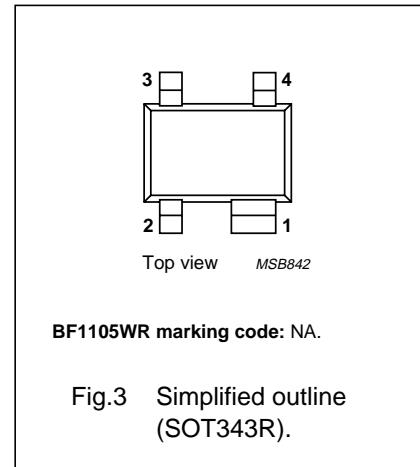
Enhancement type N-channel field-effect transistor with source and substrate interconnected. Integrated diodes between gates and source protect against excessive input voltage surges. The BF1105, BF1105R and BF1105WR are encapsulated in the SOT143B, SOT143R and SOT343R plastic packages respectively.



Top view MSB014

BF1105 marking code: NEp.

Fig.1 Simplified outline (SOT143B).



Top view MSB842

BF1105WR marking code: NA.

Fig.3 Simplified outline (SOT343R).

QUICK REFERENCE DATA

SYMBOL	PARAMETER	CONDITIONS	MIN.	TYP.	MAX.	UNIT
V_{DS}	drain-source voltage		–	–	7	V
I_D	drain current		–	–	30	mA
P_{tot}	total power dissipation	$T_{amb} \leq 80^\circ C$	–	–	200	mW
$ y_{fs} $	forward transfer admittance		25	31	–	mS
C_{ig1-ss}	input capacitance at gate 1		–	2.2	2.7	pF
C_{rss}	reverse transfer capacitance	$f = 1$ MHz	–	25	40	fF
F	noise figure	$f = 800$ MHz	–	1.7	2.5	dB
X_{mod}	cross-modulation	input level for $k = 1\%$ at 40 dB AGC	100	–	–	$dB\mu V$
T_j	operating junction temperature		–	–	150	°C

CAUTION

This product is supplied in anti-static packing to prevent damage caused by electrostatic discharge during transport and handling. For further information, refer to Philips specs.: SNW-EQ-608, SNW-FQ-302A and SNW-FQ-302B.

N-channel dual-gate MOS-FETs

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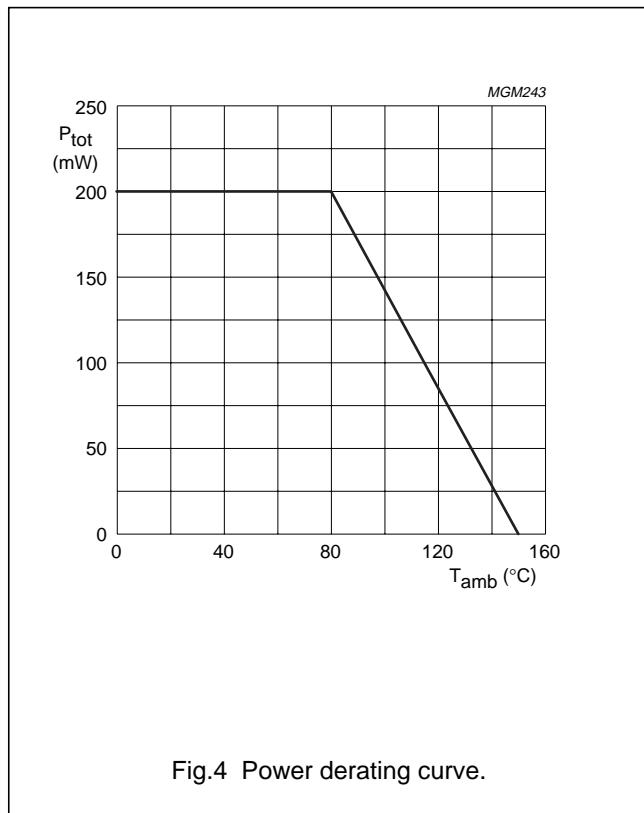
LIMITING VALUES

In accordance with the Absolute Maximum Rating System (IEC 134).

SYMBOL	PARAMETER	CONDITIONS	MIN.	MAX.	UNIT
V_{DS}	drain-source voltage		–	7	V
I_D	drain current		–	30	mA
I_{G1}	gate 1 current		–	± 10	mA
I_{G2}	gate 2 current		–	± 10	mA
P_{tot}	total power dissipation	$T_{amb} \leq 80^\circ\text{C}$; note 1; see Fig.4	–	200	mW
T_{stg}	storage temperature		–65	+150	$^\circ\text{C}$
T_j	operating junction temperature		–	+150	$^\circ\text{C}$

Note

1. Device mounted on a printed-circuit board.



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THERMAL CHARACTERISTICS

SYMBOL	PARAMETER	CONDITIONS	VALUE	UNIT
$R_{th\ j-a}$	thermal resistance from junction to ambient in free air	note 1	350	K/W
$R_{th\ j-s}$	thermal resistance from junction to soldering point		200	K/W

Note

1. Device mounted on a printed-circuit board.

STATIC CHARACTERISTICS

 $T_j = 25^\circ C$ unless otherwise specified.

SYMBOL	PARAMETER	CONDITIONS	MIN.	TYP.	MAX.	UNIT
$V_{(BR)DSS}$	drain-source breakdown voltage	$V_{G1-S} = V_{G2-S} = 0$; $I_D = 10 \mu A$	7	—	—	V
$V_{(BR)G1-ss}$	gate 1-source breakdown voltage	$V_{G2-S} = 0$; $I_D = 0$; $I_{G1-S} = 10 \mu A$	7	—	—	V
$V_{(BR)G2-ss}$	gate 2-source breakdown voltage	$V_{G1-S} = V_{DS} = 0$; $I_{G2-S} = 10 \mu A$	7	—	—	V
$V_{G2-S\ (th)}$	gate 2-source threshold voltage	$V_{G1-S} = 5 V$; $V_{DS} = 5 V$; $I_D = 20 \mu A$	0.3	0.8	1.2	V
I_{DSX}	self-biasing drain current	$V_{G2-S} = 4 V$; $V_{DS} = 5 V$	8	—	16	mA
I_{G1-ss}	gate 1 cut-off current	$V_{G1-S} = 5 V$; $V_{G2-S} = 0$; $I_D = 0$	—	—	50	nA
I_{G2-ss}	gate 2 cut-off current	$V_{G1-S} = V_{DS} = 0$; $V_{G2-S} = 4 V$	—	—	20	nA

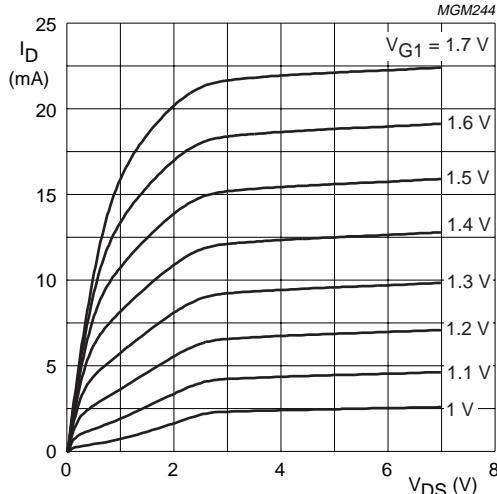
DYNAMIC CHARACTERISTICS

Common source; $T_{amb} = 25^\circ C$; $V_{G2-S} = 4 V$; $V_{DS} = 5 V$; self-biasing current; unless otherwise specified.

SYMBOL	PARAMETER	CONDITIONS	MIN.	TYP.	MAX.	UNIT
$ y_{fs} $	forward transfer admittance	pulsed; $T_j = 25^\circ C$	25	31	—	mS
C_{ig1-ss}	input capacitance at gate 1	$f = 1 MHz$	—	2.2	2.7	pF
C_{ig2-ss}	input capacitance at gate 2	$f = 1 MHz$	—	1.6	—	pF
C_{oss}	output capacitance	$f = 1 MHz$	—	1.2	—	pF
C_{rss}	reverse transfer capacitance	$f = 1 MHz$	—	25	40	fF
F	noise figure	$f = 800 MHz$; $Y_S = Y_{S\ opt}$	—	1.7	2.5	dB
G_p	power gain	$G_S = 2 mS$; $B_S = B_{S\ opt}$; $G_L = 0.5 mS$; $B_L = B_{L\ opt}$; $f = 200 MHz$; see Fig.16	—	38	—	dB
		$G_S = 3.3 mS$; $B_S = B_{S\ opt}$; $G_L = 1 mS$; $B_L = B_{L\ opt}$; $f = 800 MHz$; see Fig.17	—	20	—	dB
X_{mod}	cross-modulation	input level for $k = 1\%$ at 0 dB AGC; $f_w = 50 MHz$; $f_{unw} = 60 MHz$; see Fig.18	85	—	—	$dB\mu V$
		input level for $k = 1\%$ at 40 dB AGC; $f_w = 50 MHz$; $f_{unw} = 60 MHz$; see Fig.18	100	—	—	$dB\mu V$

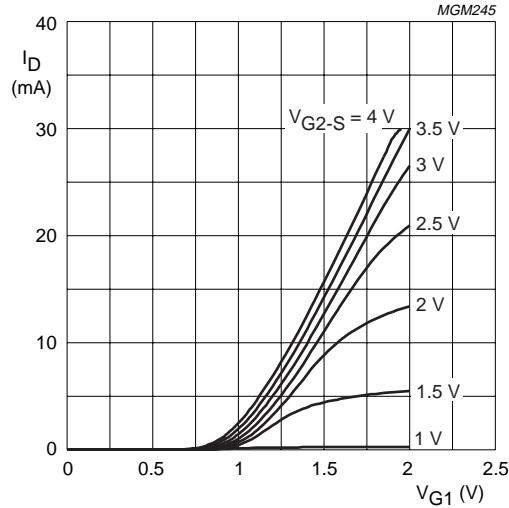
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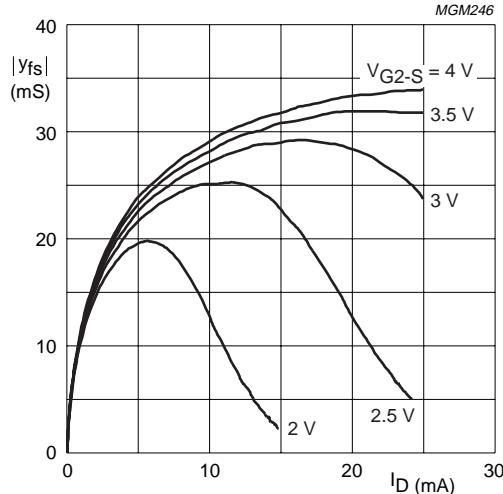
$V_{G2-S} = 4$ V.
 $T_j = 25$ °C.

Fig.5 Output characteristics; typical values.



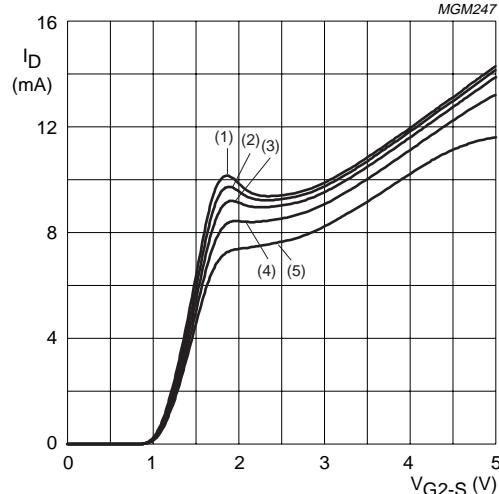
$V_{DS} = 5$ V.
 $T_j = 25$ °C.

Fig.6 Transfer characteristics; typical values.



$V_{DS} = 5$ V.
 $T_j = 25$ °C.

Fig.7 Forward transfer admittance as a function of drain current; typical values.

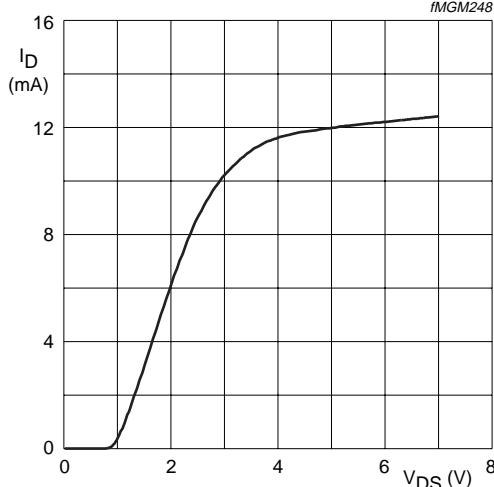


- (1) $V_{DS} = 5$ V.
- (2) $V_{DS} = 4.5$ V.
- (3) $V_{DS} = 4$ V.
- (4) $V_{DS} = 3.5$ V.
- (5) $V_{DS} = 3$ V.

Fig.8 Drain current as a function of gate 2 voltage; typical values.

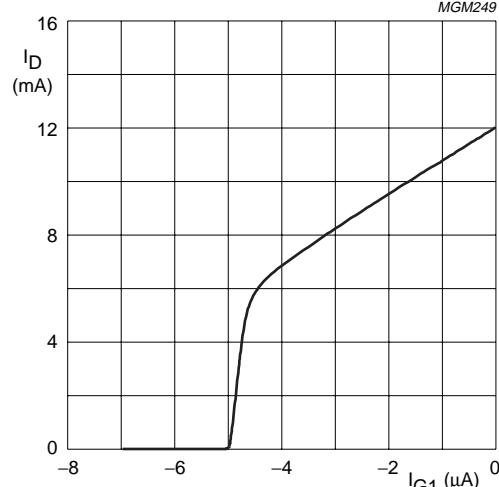
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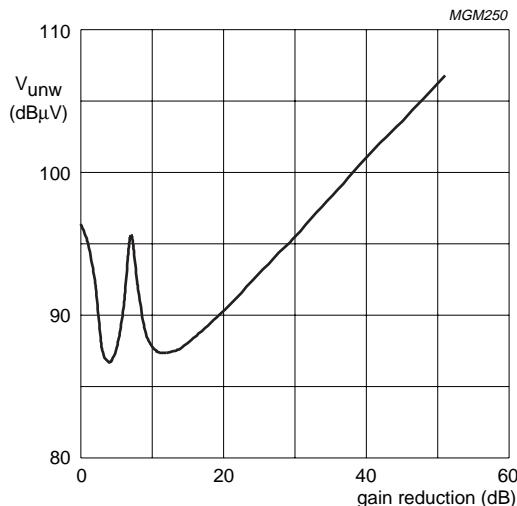
$V_{G2-S} = 4$ V.
 $T_j = 25$ °C.

Fig.9 Drain current as a function of drain-source voltage; typical values.



$V_{DS} = 5$ V; $V_{G2-S} = 4$ V; $T_j = 25$ °C.

Fig.10 Drain current as a function of gate 1 current; typical values.

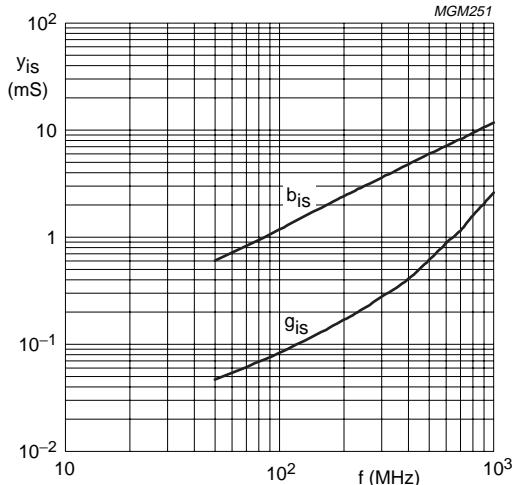


$V_{DS} = 5$ V; $V_{G2nom} = 4$ V; $I_{Dnom} = I_{self\ bias}$; $f_w = 50$ MHz;
 $f_{unw} = 60$ MHz; $T_{amb} = 25$ °C.

Fig.11 Unwanted voltage for 1% cross-modulation as a function of gain reduction; typical values (see Fig.18).

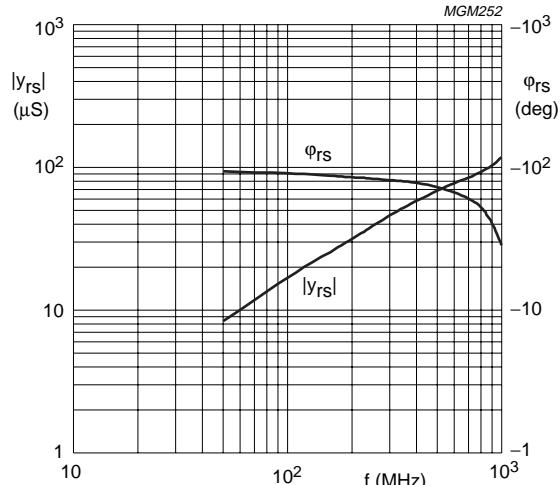
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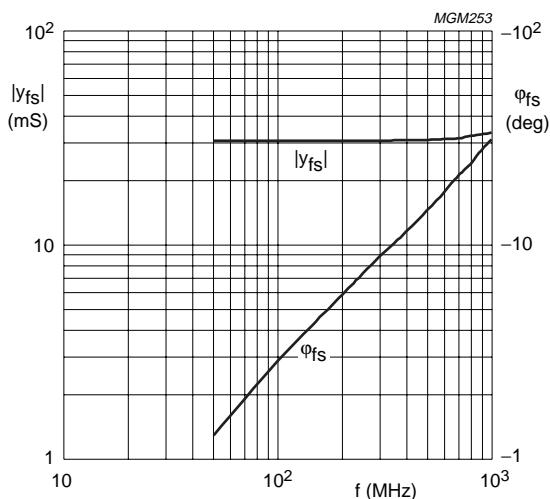
$V_{DS} = 5$ V; $V_{G2-S} = 4$ V.
 $I_D = 12$ mA; $T_{amb} = 25$ °C.

Fig.12 Input admittance as a function of frequency; typical values.



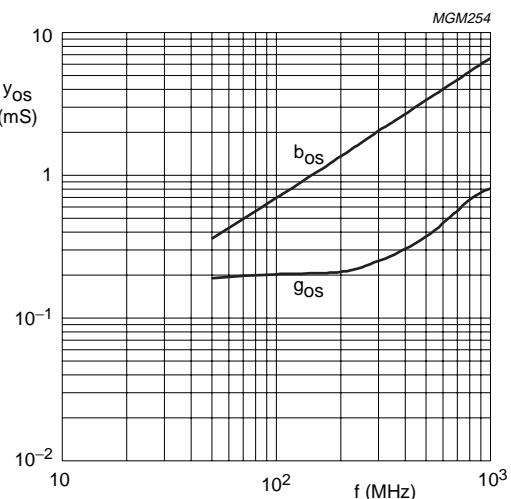
$V_{DS} = 5$ V; $V_{G2-S} = 4$ V.
 $I_D = 12$ mA; $T_{amb} = 25$ °C.

Fig.13 Reverse transfer admittance and phase as a function of frequency; typical values.



$V_{DS} = 5$ V; $V_{G2-S} = 4$ V.
 $I_D = 12$ mA; $T_{amb} = 25$ °C.

Fig.14 Forward transfer admittance and phase as a function of frequency; typical values.

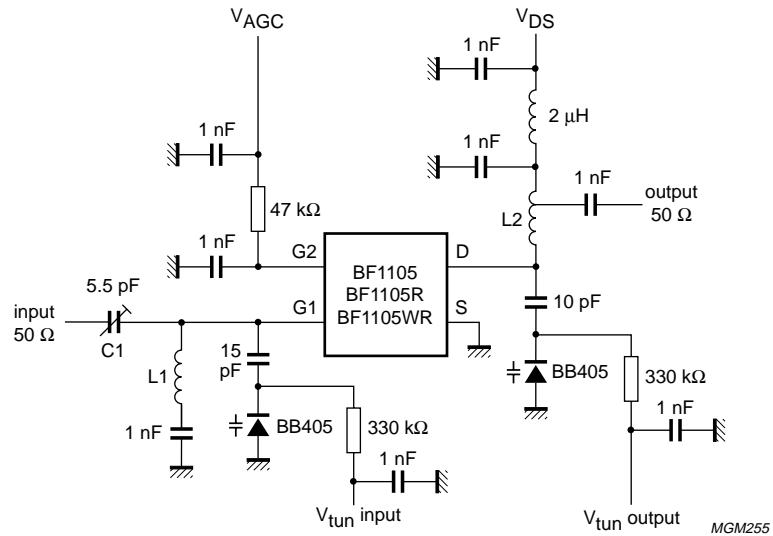


$V_{DS} = 5$ V; $V_{G2-S} = 4$ V.
 $I_D = 12$ mA; $T_{amb} = 25$ °C.

Fig.15 Output admittance as a function of frequency; typical values.

N-channel dual-gate MOS-FETs

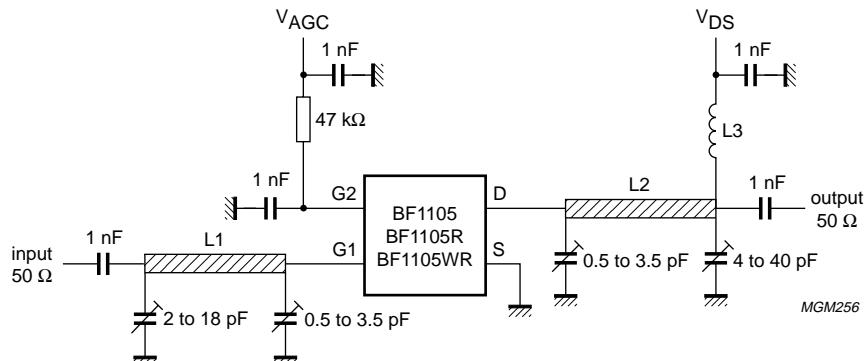
BF1105; BF1105R; BF1105WR

 $V_{DS} = 5 \text{ V}$, $G_S = 2 \text{ mS}$, $G_L = 0.5 \text{ mS}$, $f = 200 \text{ MHz}$.

L1 = 45 nH, 4 turns, internal diameter = 4 mm, 0.8 mm copper wire.

L2 = 160 nH, 3 turns, internal diameter = 8 mm, 0.8 mm copper wire; tapped at approximately half a turn from the cold side, to set $G_L = 0.5 \text{ mS}$.C1 adjusted for $G_S = 2 \text{ mS}$.

Fig.16 Gain test circuit.

 $V_{DS} = 5 \text{ V}$, $G_S = 3.3 \text{ mS}$, $G_L = 1 \text{ mS}$, $f = 800 \text{ MHz}$.

L1 = 2 cm, silvered 0.8 mm copper wire 4 mm above ground plane.

L2 = 2 cm, silvered 0.8 mm copper wire 4 mm above ground plane.

L3 = 11 turns 0.5 mm copper wire without spacing, internal diameter = 3 mm, L = approx. 200 nH.

Fig.17 Gain test circuit.

N-channel dual-gate MOS-FETs

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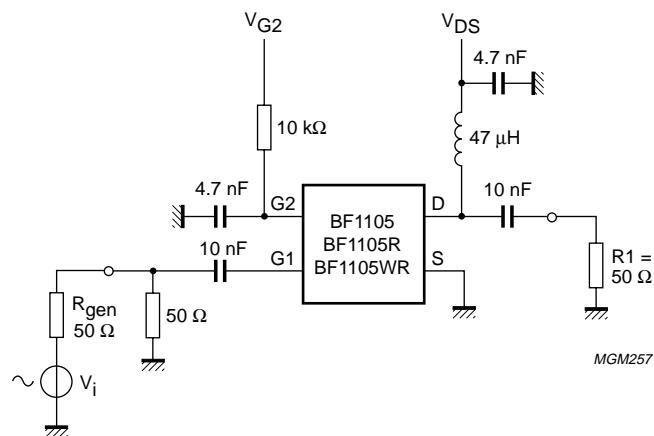


Fig.18 Cross-modulation test set-up.

Table 1 Scattering parameters: $V_{DS} = 5$ V; $V_{G2-S} = 4$ V; $I_D = 12$ mA

f (MHz)	S_{11}		S_{21}		S_{12}		S_{22}	
	MAGNITUDE (ratio)	ANGLE (deg)	MAGNITUDE (ratio)	ANGLE (deg)	MAGNITUDE (ratio)	ANGLE (deg)	MAGNITUDE (ratio)	ANGLE (deg)
50	0.994	-3.8	3.060	175.4	0.000	86.9	0.985	-2.1
100	0.991	-7.5	3.047	170.9	0.002	86.1	0.983	-4.2
200	0.982	-14.7	3.004	162.1	0.003	82.7	0.980	-8.3
300	0.968	-21.7	2.932	153.4	0.004	79.7	0.976	-12.1
400	0.956	-28.8	2.896	145.3	0.006	77.8	0.972	-16.2
500	0.937	-35.4	2.815	137.1	0.007	76.7	0.967	-20.0
600	0.918	-41.8	2.735	129.2	0.007	76.3	0.961	-23.7
700	0.897	-48.1	2.651	121.5	0.008	76.7	0.955	-27.3
800	0.878	-54.0	2.575	114.0	0.008	79.7	0.948	-30.9
900	0.858	-59.9	2.482	106.5	0.008	82.2	0.941	-34.4
1000	0.840	-65.5	2.396	99.5	0.008	88.0	0.935	-37.9

Table 2 Noise data: $V_{DS} = 5$ V; $V_{G2-S} = 4$ V; $I_D = 12$ mA

f (MHz)	F_{min} (dB)	Γ_{opt}		R_n (Ω)
		(ratio)	(deg)	
800	1.5	0.674	39.7	37.15

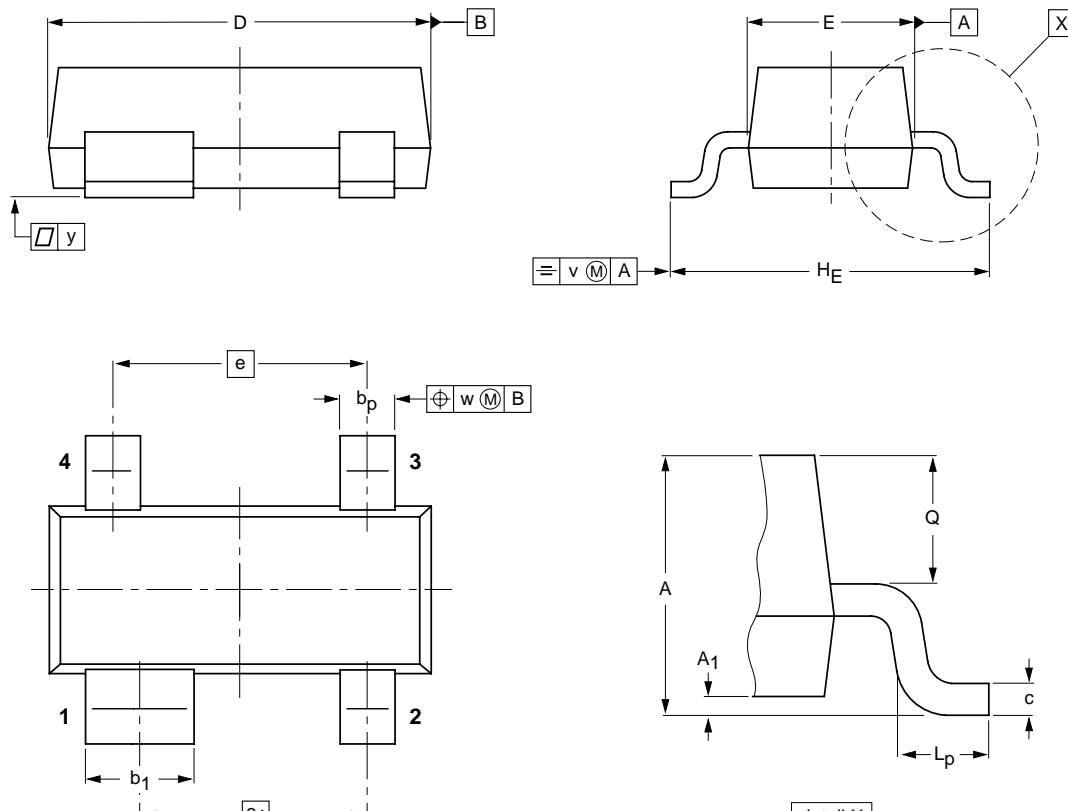
N-channel dual-gate MOS-FETs

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PACKAGE OUTLINES

Plastic surface mounted package; 4 leads

SOT143B



0 1 2 mm
scale

DIMENSIONS (mm are the original dimensions)

UNIT	A	A ₁ max	b _p	b ₁	c	D	E	e	e ₁	H _E	l _p	Q	v	w	y
mm	1.1 0.9	0.1	0.48 0.38	0.88 0.78	0.15 0.09	3.0 2.8	1.4 1.2	1.9	1.7	2.5 2.1	0.45 0.15	0.55 0.45	0.2	0.1	0.1

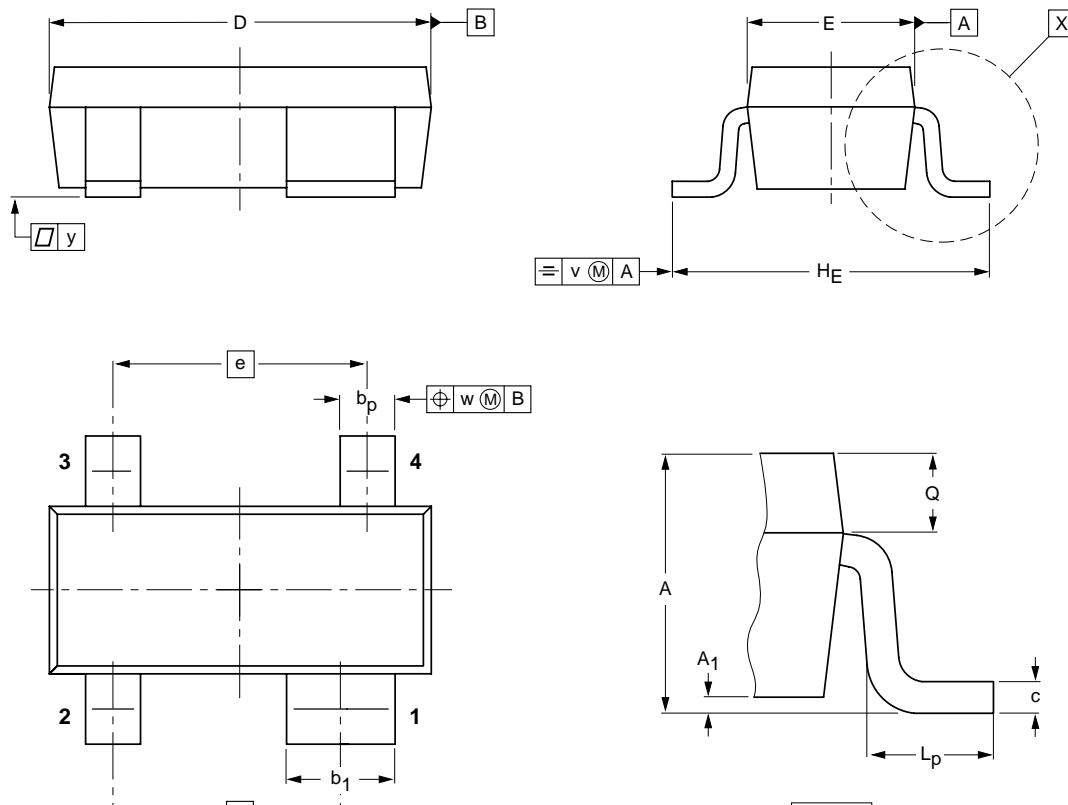
OUTLINE VERSION	REFERENCES				EUROPEAN PROJECTION	ISSUE DATE
	IEC	JEDEC	EIAJ			
SOT143B						97-02-28

N-channel dual-gate MOS-FETs

BF1105; BF1105R; BF1105WR

Plastic surface mounted package; reverse pinning; 4 leads

SOT143R



0 1 2 mm
scale

DIMENSIONS (mm are the original dimensions)

UNIT	A	A ₁ max	b _p	b ₁	c	D	E	e	e ₁	H _E	L _p	Q	v	w	y
mm	1.1 0.9	0.1	0.48 0.38	0.88 0.78	0.15 0.09	3.0 2.8	1.4 1.2	1.9	1.7	2.5 2.1	0.55 0.25	0.45 0.25	0.2	0.1	0.1

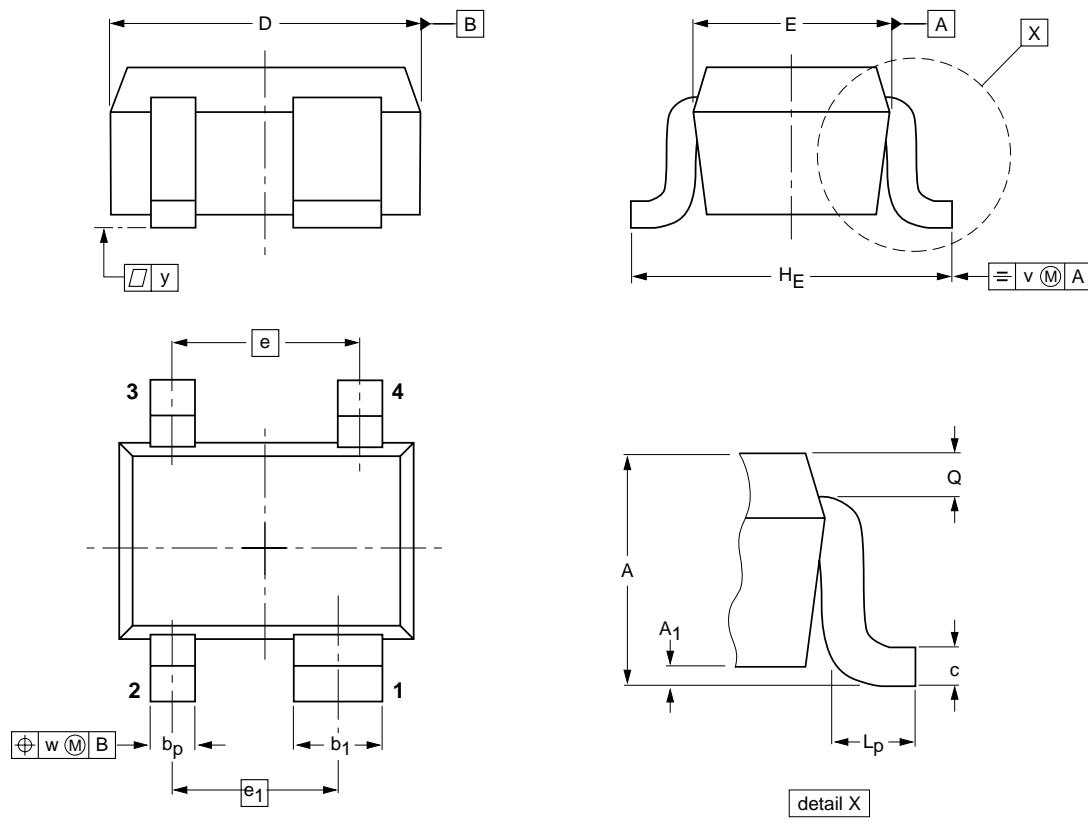
OUTLINE VERSION	REFERENCES				EUROPEAN PROJECTION	ISSUE DATE
	IEC	JEDEC	EIAJ			
SOT143R						97-03-10

N-channel dual-gate MOS-FETs

BF1105; BF1105R; BF1105WR

Plastic surface mounted package; reverse pinning; 4 leads

SOT343R



0 1 2 mm
scale

DIMENSIONS (mm are the original dimensions)

UNIT	A	A_1 max	b_p	b_1	c	D	E	e	e_1	H_E	L_p	Q	v	w	y
mm	1.1 0.8	0.1	0.4 0.3	0.7 0.5	0.25 0.10	2.2 1.8	1.35 1.15	1.3	1.15	2.2 2.0	0.45 0.15	0.23 0.13	0.2	0.2	0.1

OUTLINE VERSION	REFERENCES				EUROPEAN PROJECTION	ISSUE DATE
	IEC	JEDEC	EIAJ			
SOT343R						97-05-21

N-channel dual-gate MOS-FETs**BF1105; BF1105R; BF1105WR****DEFINITIONS**

Data Sheet Status	
Objective specification	This data sheet contains target or goal specifications for product development.
Preliminary specification	This data sheet contains preliminary data; supplementary data may be published later.
Product specification	This data sheet contains final product specifications.
Limiting values	
Limiting values given are in accordance with the Absolute Maximum Rating System (IEC 134). Stress above one or more of the limiting values may cause permanent damage to the device. These are stress ratings only and operation of the device at these or at any other conditions above those given in the Characteristics sections of the specification is not implied. Exposure to limiting values for extended periods may affect device reliability.	
Application information	
Where application information is given, it is advisory and does not form part of the specification.	

LIFE SUPPORT APPLICATIONS

These products are not designed for use in life support appliances, devices, or systems where malfunction of these products can reasonably be expected to result in personal injury. Philips customers using or selling these products for use in such applications do so at their own risk and agree to fully indemnify Philips for any damages resulting from such improper use or sale.

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NOTES

N-channel dual-gate MOS-FETs

BF1105; BF1105R; BF1105WR

NOTES

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